

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Byung-Sup SHIM et al.

Serial No.

09/305,240

Examiner:

O. Nadav

Filed:

May 4, 1999

Group Art Unit:

2811

For:

OPEN DRAIN INPUT/OUTPUT STRUCTURE AND MANUFACTURING

METHOD THEREOF IN SEMICONDUCTOR DEVICE

Date: March 9, 2000

Box Non-Fee Amendment Commissioner of Patents and Trademarks, Washington, D.C. 20231

## RESPONSE TO RESTRICTION REQUIREMENT

Responsive to the Office Action, dated February 17, 2000, please amend the application as follows.

## IN THE CLAIMS:

Applicant elects claims 5-9, drawn to a semiconductor device, without traverse.

## REMARKS

Applicant respectfully submits that each of the Examiner's rejections have been overcome and that this Application is in condition for allowance. Such is respectfully requested.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231

Date: March 9, 2000

Respectfully submitted,

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